

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	181	(438/602).CCLS	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/06/13 09:38
S1	2196	((silicon or ("Si")) adj substrate) with ((SiGe) or ((silicon or ("Si")) adj (germanium or ("Ge"))))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/07 11:36
S2	37	((silicon or ("Si")) adj substrate) with (((SiGe) or ((silicon or ("Si")) adj (germanium or ("Ge")))) adj (layer or film)) with (dop\$6 or implant\$6) with (hydrogen or ("H. sub.2"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:57
S3	1	((silicon or ("Si")) adj substrate) with (((SiGe) or ((silicon or ("Si")) adj (germanium or ("Ge")))) adj (layer or film)) with (dop\$6 or implant\$6) with (hydrogen or ("H. sub.2")) with (anneal\$6) with ((silicon or ("si")) adj (layer or film))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/06 14:56
S4	3	((("6464780") or ("6562703") or ("20030143783")).PN.	US-PGPUB; USPAT	OR	OFF	2005/06/06 14:56